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Semiconductor devices - Micro-electromechanical devices - Part 15: Test method of bonding strength between PDMS and glass

Táto norma obsahuje anglickú verziu európskej normy.  
This standard includes the English version of the European Standard.

Táto norma bola oznámená vo Vestníku ÚNMS SR č. 11/15

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EUROPEAN STANDARD

**EN 62047-15**

NORME EUROPÉENNE

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July 2015

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## English Version

**Semiconductor devices - Micro-electromechanical devices - Part  
15: Test method of bonding strength between PDMS and glass  
(IEC 62047-15:2015)**

Dispositifs à semiconducteurs - Dispositifs  
microélectromécaniques - Partie 15: Méthode d'essai de la  
résistance de collage entre PDMS et verre  
(IEC 62047-15:2015)

Halbleiterbauelemente - Bauelemente der  
Mikrosystemtechnik - Teil 15: Prüfverfahren zur  
Bondqualität zwischen PDMS und Glas  
(IEC 62047-15:2015)

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**European foreword**

The text of document 47F/208/FDIS, future edition 1 of IEC 62047-15, prepared by SC 47F "Microelectromechanical systems" of IEC/TC 47 "Semiconductor devices" was submitted to the IEC-CENELEC parallel vote and approved by CENELEC as EN 62047-15:2015.

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<u>Publication</u>	<u>Year</u>	<u>Title</u>	<u>EN/HD</u>	<u>Year</u>
IEC 62047-9	-	Semiconductor devices - Micro-electromechanical devices -- Part 9: Wafer to wafer bonding strength measurement for MEMS	EN 62047-9	-



# INTERNATIONAL STANDARD

## NORME INTERNATIONALE



**Semiconductor devices – Micro-electromechanical devices –  
Part 15: Test method of bonding strength between PDMS and glass**

**Dispositifs à semiconducteurs – Dispositifs microélectromécaniques –  
Partie 15: Méthode d'essai de la résistance de collage entre PDMS et verre**





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# INTERNATIONAL STANDARD

# NORME INTERNATIONALE



**Semiconductor devices – Micro-electromechanical devices –  
Part 15: Test method of bonding strength between PDMS and glass**

**Dispositifs à semiconducteurs – Dispositifs microélectromécaniques –  
Partie 15: Méthode d'essai de la résistance de collage entre PDMS et verre**

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## INTERNATIONAL ELECTROTECHNICAL COMMISSION

**SEMICONDUCTOR DEVICES –  
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strength between PDMS and glass****FOREWORD**

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The text of this standard is based on the following documents:

FDIS	Report on voting
47F/208/FDIS	47F/213/RVD

Full information on the voting for the approval of this standard can be found in the report on voting indicated in the above table.

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## SEMICONDUCTOR DEVICES – MICRO-ELECTROMECHANICAL DEVICES –

### **Part 15: Test method of bonding strength between PDMS and glass**

#### **1 Scope**

This part of IEC 62047 describes test method for bonding strength between poly dimethyl siloxane (PDMS) and glass. Silicone-based rubber, PDMS, is used for building of chip-based microfluidic devices fabricated using lithography and replica moulding processes. The problem of bonding strength is mainly for high pressure applications as in the case of certain peristaltic pump designs where an off chip compressed air supply is used to drive the fluids in micro channels created by a twin layer, one formed by bondage between glass with replica moulded PDMS and another between PDMS and PDMS. Also, in case of systems having pneumatic microvalves, a relatively high level of bonding particularly between two replica moulded layers of PDMS becomes quite necessary. Usually there is a leakage and debonding phenomena between interface of bonded areas, which causes instability and shortage of lifetime for MEMS devices. This standard specifies general procedures on bonding test of PDMS and glass chip.

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